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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re PATENT APPLICATION of

Ho-Woo Park et al.

Group Art Unit: 2822

Application No. 10/807,437

Examiner: Thomas, Toniae M.

Filed: March 24, 2004

For: SEMICONDUCTOR DEVICE INCLUDING AIR GAP BETWEEN
SEMICONDUCTOR SUBSTRATE AND L-SHAPED SPACER AND METHOD
OF FABRICATING THE SAME

RESPONSE TO ELECTION/RESTRICTION REQUIREMENT


U.S. Patent and Trademark Office
Customer Service Window, Mail Stop Amendment
Randolph Building
401 Dulany Street
Alexandria VA 22314

Sir:

In response to the Office Action of July 22, 2005, Applicants elect the invention of
Group I, Claims 1-5, drawn to a semiconductor device. The election is without traverse.

Respectfully submitted,

VOLENTINE FRANCOS & WHITT, PLLC


Adam C. Volentine
Registration No. 33,289

One Freedom Square
11951 Freedom Drive, Suite 1260
Reston VA 21090
Tel. (571) 283-0720
Fax (571) 283-0740

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